

## §16. Examination of Electrical Degradation of Ceramic Coating Materials Using Ion Beam Irradiation

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In the development of the electrical insulating coating for the liquid Li cooled blanket system, radiation damage is one of the concerned factors degrading the performance. Previous studies on  $\text{Al}_2\text{O}_3$  insulators have reported the possibility of RIED (Radiation Induced Electrical Degradation), which is permanent electrical degradation due to irradiation damage, under the condition of high neutron fluence, high temperature and high electric field. However, almost no data is available for the irradiation effects on the candidate coating materials such as  $\text{Er}_2\text{O}_3$ ,  $\text{Y}_2\text{O}_3$ ,  $\text{CaZrO}_3$ ,  $\text{AlN}$  etc. The objective of the present study is to examine the effect of irradiation damage on the ceramic materials using a high-energy ion beam. Result of preliminary irradiation experiment on  $\text{Er}_2\text{O}_3$  coating is described in this report.

Schematic arrangement of the ion beam irradiation is shown in Fig.1. A sample of  $\text{Er}_2\text{O}_3$  coating was made on a stainless steel plate of  $15 \times 15 \times 2 \text{ mm}^3$  by the RF sputtering method at University of Tokyo. Thickness of the coating was  $1 \mu\text{m}$ . Electrical performance of the coating sample was examined at NIFS. On the surface of the coating, three Pt electrodes of  $2 \times 2 \text{ mm}^2$  were made by sputter deposition with thickness of  $\sim 100 \text{ nm}$ . Bias voltage was applied to the stainless steel plate. Electrical insulating performance of the coating was evaluated by measurement of currents flowing into the electrodes. The electrical conductivities under the three electrodes were  $1.7 \times 10^{-10}$ ,  $5.4 \times 10^{-11}$  and  $6.9 \times 10^{-10} \text{ S/m}$ .

Ion beam irradiation was performed in Institute for Materials Research of Tohoku University. A beam of  $1 \text{ MeV H}^+$  was collimated to  $1 \text{ mm}$  in diameter and injected into the Pt electrodes. During the irradiation, the electrodes were grounded to prevent electrical breakdown due to charge up in the coating layer. The irradiation flux of the  $\text{H}^+$  beam was  $7.9 \times 10^{11} \text{ H/cm}^2/\text{s}$ . The total fluences at the three electrodes were  $1.0 \times 10^{15}$ ,  $1.0 \times 10^{16}$  and  $2.6 \times 10^{16} \text{ H/cm}^2$ , respectively.

Figure 2 shows examples of current-voltage (I-V) characteristics measured before and after the ion beam irradiation. Both of the curves indicate ohmic characteristics. Electrical conductivities after the irradiation were  $2.6 \times 10^{-10} \text{ S/m}$  (fluence:  $1.0 \times 10^{15} \text{ H/cm}^2$ , conductivity before irradiation:  $1.7 \times 10^{-10} \text{ S/m}$ ),  $9.6 \times 10^{-10} \text{ S/m}$  ( $1.0 \times 10^{16}$

$\text{H/cm}^2$ ,  $5.4 \times 10^{-11} \text{ S/m}$ ) and  $1.3 \times 10^{-7} \text{ S/m}$  ( $2.6 \times 10^{16} \text{ H/cm}^2$ ,  $6.9 \times 10^{-10} \text{ S/m}$ ), respectively. Significant change was observed for the order of  $1.0 \times 10^{16} \text{ H/cm}^2$  in the present experiment. By calculation using the charged particle transportation code TRIM, it is estimated coarsely that the range of hydrogen ions was  $5\text{-}10 \mu\text{m}$  in the  $\text{Er}_2\text{O}_3$  layer and displacement after the irradiation of  $2.6 \times 10^{16} \text{ H/cm}^2$  corresponded to  $\sim 0.005 \text{ dpa}$ .

Further irradiation is planned to examine the relation between the insulating performance and various factors of fluence, temperature, applied electric field etc. Examination of luminescence emission spectrum under ion beam irradiation is also planned to obtain information on the defect formation.

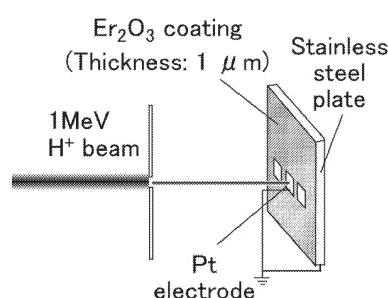


Fig. 1 Schematic arrangement of ion beam irradiation on  $\text{Er}_2\text{O}_3$  coating.

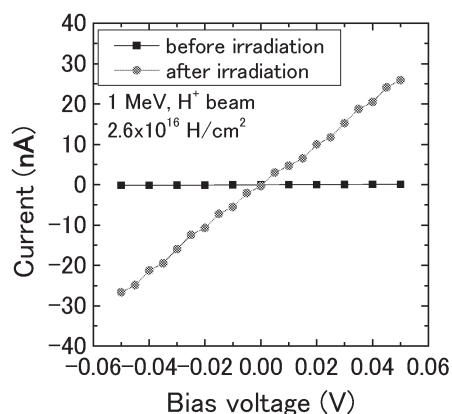


Fig. 2 Example of current-voltage (I-V) characteristics before and after irradiation (Electrode:  $2 \times 2 \text{ mm}^2$ , Thickness of coating:  $1 \mu\text{m}$ )